

# United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/764,207	01/19/2001	Ming-Yi Lay	0941-0213P-SP	7484
34003	7590 11/17/2004		EXAM	INER
INTELLECTUAL PROPERTY SOLUTIONS, INCORPORATED 5717 COLFAX AVENUE			WILCZEWSKI, MARY A	
	IA, VA 22311		ART UNIT	PAPER NUMBER
	•		2822	

DATE MAILED: 11/17/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant/al
		Application No.	Applicant(s)
		09/764,207	LAY ET AL.
	Office Action Summary	Examiner	Art Unit
	·	Mary Wilczewski	2822
eriod f	The MAILING DATE of this communication or Reply	appears on the cover sheet w	ith the correspondence address
THE - External control	ORTENED STATUTORY PERIOD FOR REMAILING DATE OF THIS COMMUNICATIOnsions of time may be available under the provisions of 37 CF SIX (6) MONTHS from the mailing date of this communication period for reply specified above is less than thirty (30) days, a period for reply is specified above, the maximum statutory period for reply within the set or extended period for reply will, by size to reply within the set or extended period for reply will, by size reply received by the Office later than three months after the need patent term adjustment. See 37 CFR 1.704(b).	ON. R 1.136(a). In no event, however, may a in. r. a reply within the statutory minimum of thireriod will apply and will expire SIX (6) MON tatute, cause the application to become Al	reply be timely filed ty (30) days will be considered timely. NTHS from the mailing date of this communication. BANDONED (35 U.S.C. § 133).
tatus			
1)🖂	Responsive to communication(s) filed on 1	2 July 2004.	
2a)□	_	This action is non-final.	
3)□	Since this application is in condition for allo	owance except for formal mat	ters, prosecution as to the merits is
	closed in accordance with the practice und	ler <i>Ex parte</i> Q <i>uayl</i> e, 1935 C.D	D. 11, 453 O.G. 213.
isposit	ion of Claims		
4)🖂	Claim(s) 1,3,4 and 6-10 is/are pending in t	he application.	
	4a) Of the above claim(s) is/are with	drawn from consideration.	
5)□	Claim(s) is/are allowed.		
6)🖂	Claim(s) 1.4 and 6-10 is/are rejected.		
7)🖂	Claim(s) 3 is/are objected to.		
8)[	Claim(s) are subject to restriction a	nd/or election requirement.	
pplicat	ion Papers		
9)[	The specification is objected to by the Exar	miner.	
10)⊠	The drawing(s) filed on 19 January 2001 is	/are: a)⊠ accepted or b)□ c	bjected to by the Examiner.
	Applicant may not request that any objection to	the drawing(s) be held in abeya	nce. See 37 CFR 1.85(a).
	Replacement drawing sheet(s) including the co	· · · · · · · · · · · · · · · · · · ·	
11)[_]	The oath or declaration is objected to by the	e Examiner. Note the attache	d Office Action or form PTO-152.
riority	under 35 U.S.C. § 119		
•	Acknowledgment is made of a claim for fore	eign priority under 35 U.S.C.	§ 119(a)-(d) or (f).
a)	All b) Some * c) None of:      Certified copies of the priority documents.	ante have heen received	
	<ol> <li>Certified copies of the priority docum</li> <li>Certified copies of the priority docum</li> </ol>		Application No.
	3. Copies of the certified copies of the		
	application from the International Bu	•	Toosived in this Hadional Stage
* (	See the attached detailed Office action for a	1. 1	received.
tachmer	ot(s)	•	

1) 🔯	Notice of	of References	Cited	(PTO-892)
------	-----------	---------------	-------	-----------

2) Notice of Draftsperson's Patent Drawing Review (PTO-948)
3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)
Paper No(s)/Mail Date 7/12/04.

4)	Ш	Interview Summary (PTO-413)
		Paper No(s)/Mail Date.

5) Notice of Informal Patent Application (PTO-152)

6)	Ш	Other:	
----	---	--------	--

### **DETAILED ACTION**

This Office action is in response to the Request For Continued Examination and Information Disclosure Statement filed on July 12, 2004.

### Continued Examination Under 37 CFR 1.114

A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after allowance or after an Office action under *Ex Parte Quayle*, 25 USPQ 74, 453 O.G. 213 (Comm'r Pat. 1935). Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, prosecution in this application has been reopened pursuant to 37 CFR 1.114. Applicant's submission filed on July 12, 2004, has been entered.

### **Priority**

Receipt is acknowledged of papers submitted under 35 U.S.C. 119(a)-(d), which papers have been placed of record in the file.

#### **Drawings**

The drawings filed on January 19, 2001, are acceptable.

## Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

Claims 1, 4, and 6-9 are rejected under 35 U.S.C. 102(b) as being clearly anticipated by Kim, Korean Patent 00171099, cited by Applicants in the IDS filed July 12, 2004.

Kim discloses a plurality of metal bumps comprising at least a first metal bump 16 having a first sidewall, the first sidewall comprising a first predetermined area; a second bump 17 having a second sidewall, the second sidewall comprising a second predetermined area adjacent to the first predetermined area; wherein the first predetermined area is covered with an oxide insulating layer 18 and the second predetermined area is not covered by the insulating layer, see figures 3d, 3e, and 4. In the method of Kim the second bump 17 is formed atop the first bump 16, with sidewalls of the first bump 16 and the second bump 17 adjacent to one another in the vertical direction. The claims, as presently drafted, do not preclude this arrangement of metal bumps.

Application/Control Number: 09/764,207

Art Unit: 2822

Claims 1, 4, and 6-10 are rejected under 35 U.S.C. 102(e) as being clearly anticipated by Kim et al., U.S. Patent 6,232,563, of record.

Kim et al. '563 disclose a plurality of metal bumps for connecting a glass substrate and a semiconductor chip comprising at least a first metal bump 16 having a first sidewall, the first sidewall comprising a first predetermined area; a second bump 17 having a second sidewall formed atop the first bump, the second sidewall comprising a second predetermined area adjacent to the first predetermined area; wherein the first predetermined area is covered with an oxide insulating layer 18 and the second predetermined area is not covered by the insulating layer, see figures 3d, 3e, and 4. The metal bumps are formed on a bond pad 12 on semiconductor substrate 11 and connected to the bond pad 21 formed on substrate 22 by using an anisotropic conductive film (19, 20), see figure 4 and column 1, lines 21-38; column 3, lines 41-42 and 63-64 and column 4, lines 4-25. In the method of Kim the second bump 17 is formed atop the first bump 16, with sidewalls of the first bump 16 and the second bump 17 adjacent to one another in the vertical direction. The claims, as presently drafted, do not preclude this arrangement of metal bumps.

#### Conclusion

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. The three cited Japanese patents were submitted with Applicants' Information Disclosure Statement filed July 12, 2004, but were not cited thereon.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Mary Wilczewski whose telephone number is (571) 272-1849. The examiner can normally be reached on Monday and Thursday.

The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Mary Wilczewski Primary Examiner Tech Center 2800